Freeform Search

(manufacture)					
Database:	US Pre-Grant Publication Fu US Patents Full-Text Database US OCR Full-Text Database EPO Abstracts Database JPO Abstracts Database Derwent World Patents Inde IBM Technical Disclosure Bu	x			
Term:	L2 and (milliequivale	nt or milli-equival	lent)		
Display: Generate:	Documents in <u>Disp</u> ○ Hit List ⊙ Hit Coun	-	tarting with Number	1	
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Search History					
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<u>L4</u>	L2 and (milliequivalent or milli-equivalent)	4	<u>L4</u>
<u>L3</u>	L2 and (density or charge or milliequivalent or milli-equivalent)	25	<u>L3</u>
<u>L2</u>	L1 and (textile or woven or (non near2 woven) or fabric or cloth)	48	<u>L2</u>
<u>L1</u>	(LI-SHULONG\$ or BRANDON-ANTHONY\$).in.	48	<u>L1</u>

END OF SEARCH HISTORY